

	Type	Hits	Search Text	DBs
1	BRS	91	undoped adj silicon near oxide and silicon near dioxide and (opening or via or hole or aperture or cavity)	USPAT
2	BRS	14	undoped adj silicon near oxide and doped adj silicon near dioxide and (opening or via or hole or aperture or cavity)	USPAT
3	BRS	0	undoped adj silicon near oxide and doped adj silicon near dioxide and (opening or via or hole or aperture or cavity)	JPO
4	BRS	0	silicon near oxide and doped adj silicon near dioxide and (opening or via or hole or aperture or cavity)	JPO
5	BRS	5	undoped adj silicon near oxide and (opening or via or hole or aperture or cavity)	JPO
6	BRS	2	3886569.pn. or 5275972.pn.	USPAT; JPO
7	BRS	0	257/750 and undoped adj silicon near oxide and doped adj silicon near dioxide and (opening or via or hole or aperture or cavity)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM TDB
8	BRS	0	257/754 and undoped adj silicon near oxide and doped adj silicon near dioxide and (opening or via or hole or aperture or cavity)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM TDB

	Type	Hits	Search Text	DBs
9	BRS	0	257/755 and undoped adj silicon near oxide and doped adj silicon near dioxide and (opening or via or hole or aperture or cavity)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM TDB
10	BRS	0	257/756 and undoped adj silicon near oxide and doped adj silicon near dioxide and (opening or via or hole or aperture or cavity)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM TDB
11	BRS	0	257/757 and undoped adj silicon near oxide and doped adj silicon near dioxide and (opening or via or hole or aperture or cavity)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM TDB
12	BRS	0	257/759 and undoped adj silicon near oxide and doped adj silicon near dioxide and (opening or via or hole or aperture or cavity)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM TDB
13	BRS	0	257/773 and undoped adj silicon near oxide and doped adj silicon near dioxide and (opening or via or hole or aperture or cavity)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM TDB

	Type	Hits	'Search Text	DBs
14	BRS	1	257/774 and undoped adj silicon near oxide and doped adj silicon near dioxide and (opening or via or hole or aperture or cavity)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM TDB
15	BRS	1	257/760 and undoped adj silicon near oxide and doped adj silicon near dioxide and (opening or via or hole or aperture or cavity)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM TDB
16	BRS	9	257/\$.ccls. and undoped adj silicon near oxide and doped adj silicon near dioxide and (opening or via or hole or aperture or cavity)	USPAT; US-PGP UB; EPO; JPO; DERWEN T; IBM TDB

	Type	Hits	Search Text	DBs
1	BRS	16	4806199.pn. or 4807016.pn. or 5286344.pn. or 5300463.pn. or 5424570.pn. or 5468342.pn. or 5562801.pn. or 5626716.pn. or 5695658.pn. or 5814563.pn. or 5817580.pn. or 5841195.pn. or 5843845.pn. or 5843847.pn. or 5855962.pn. or 5965035.pn.	USPAT
2	BRS	46	doped adj silicon near oxide and silicon near dioxide and (opening or via or hole or aperture or cavity) and spacers	USPAT
3	BRS	389	doped and undoped and (silicon near oxide) and silicon near dioxide and (opening or via or hole or aperture or cavity) and spacers	USPAT
4	BRS	1	5286344.pn.	USPAT
5	BRS	65	5286344.uref.	USPAT
6	BRS	182	doped adj silicon near oxide and silicon near dioxide and (opening or via or hole or aperture or cavity)	USPAT
7	BRS	1	5880036.pn.	USPAT
8	BRS	389	doped and undoped and (silicon near oxide) and (silicon near dioxide) and (opening or via or hole or aperture or cavity) and spacers	USPAT

	Time Stamp
1	2001/07/26 18:02
2	2001/07/26 16:02
3	2001/07/27 18:12
4	2001/07/26 16:51
5	2001/07/26 16:51
6	2001/07/27 19:50
7	2001/07/26 18:03
8	2001/07/27 18:13